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Chemical force microscopy for hot-embossing lithography release layer characterization

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We employed variable temperature chemical force microscopy (VT-CFM) using tips silanized with four different hydro- and hydrofluoroalkyl self-assembling monolayers (SAMs) interacting with a thin-film of poly(cyclic olefin), (PCO) to model the hot-embossing stamp-polymer interaction over a temperature range spanning the glass transition of the PCO.

Introduction

High cost, slow serial throughput and resolution issues often handicap traditional micro and nanofabrication techniques. Therefore, to meet the challenges of the microelectronics, optics, MEMS, and BioMEMS industries, researchers look to next generation lithography techniques.¹ Among the technologies being re-invented to this end is hot-embossing lithography (HEL), an example of NanoImprint Lithography (NIL). $2-4$ HEL facilitates the fabrication of miniaturized devices with several advantages: resolution on the order of polymer coil dimensions, low long-term cost, flexibility, production of copies which are the near-perfect replication of the pattern, and minimum dimensions in the sub 10 nm range. HEL is promising for optical, biological and datastorage devices as well as semiconductor integrated circuits.⁵

Esch *et. al.*⁶ and others have investigated the role of stamp design and geometry, showing results for embossing with orthogonal stamp features as well as for more open pyramidal structures. We have initiated a systematic study of rheological and interfacial effects for nano-imprint lithography. In HEL, a raw, textured wafer is pressed into a thermoplastic polymer heated above its T_g (Fig. 1A). As the stamp progresses into the material, the displaced polymer is pushed into the 'bulk' reservoir for relatively thick films. However as the stamp motifs reach the end of the stroke, the film remaining between the stamp and the substrate may approach the tribological regime where surface effects from both the stamp and the substrate act on the highly confined polymer.⁷ For this non-equilibrium viscoelastic system during the embossing and de-embossing phases, a greater understanding of the surface interactions is required with model systems including the 'perfluoro' surface as described below. In the absence of release layers, significant damage to the embossed polymer, the stamp, or both is often observed as illustrated in Fig. 1B.

Measuring adhesion at the nanoscale is possible due to the development of atomic force microscopy^{8,9} (AFM or scanning

probe microscopy, SPM) that provides instrumentation for the relatively new field of micro and nanotribology. Interfacial processes such as adhesion, friction, scratching, wear, indentation and lubrication are now routinely investigated from the atomic-, molecular- and micro-scales. $10,11$ In order to model the embossing process with AFM (Fig. 1C), we functionalized SPM tips with selected alkylsilanes with a varying degree of perfluorination (Fig. 1D) and then brought these tips into contact with a polymer

Fig. 1 Schematic representation of the hot-embossing process (A), the effect of embossing with and without release layers (B), the SPM analogue experiment (C) and a micrograph of a silane-functionalized tip and schematic indicating the effect of tip geometry on the SAM (D).

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thin-film of PCO at four temperatures: 20, 60, 80, and 100 $^{\circ}$ C. While many polymers have been routinely investigated for NIL including poly(methyl methacrylate) (PMMA), polycarbonate (PC), polystyrene (PS) and others, the poly(cyclic olefins) (PCO) and cyclic olefin copolymers (COC), are increasingly popular. Zeonor 750R is a commercial-grade, fully saturated PCO with good optical properties, high chemical resistance, acceptable thermoformability and has a relatively accessible T_g for these VT-CFM experiments.¹² The temperature range was selected to span the glass transition of the polymer (72 °C).¹³ We measured the force required to disengage the tip from the polymer. As Bhushan describes in some detail, 11 force–displacement plots provide a deceptively simple method of determining surface adhesion. When a tip is lowered near a surface, at some critical distance, van der Waals, electrostatic or other forces overwhelm the cantilever spring constant and the tip 'snaps-to' the surface. The tip is lowered further to a point determined by the user and then retraction may begin. During retraction, the force is negative and adhesion maintains the tip–sample contact as the negative tensile load increases through the point of maximum adhesion to an unstable regime where the cantilever stiffness is stronger than the tip–sample interaction and the contact is broken. From the cantilever spring constant (*k*) and displacement (*l*), one can calculate the pull-off force (see eqn 1).

$$
F(nN) = k(N/m)^* l(nm)
$$
 (1)

While the pull-off force is not equal to, but rather exceeds the true adhesion force, 14 the distinction is not critical for the comparative study we describe below and for simplicity, we use the terms interchangeably. The separation force in similar systems has been reported to exceed pure surface-energy derived values substantially.¹⁵ The explanation for this difference may well lie in the mechanics of viscoelastic crack healing and adhesion as discussed in some detail by Baney and Hui *et al*. 16–18 In compliance-controlled experiments such as ours, the coupled compliance of the cantilever will determine the deviation of the pull-off force from the force of adhesion.¹⁹ Elegant displacement controlled methods have been developed and used by others to avoid the issue.²⁰ Recent work has shown that frequency modulation can also be exploited to extract interaction parameters.^{21,22}

Hydrofluoroalkyl materials defined the interface under investigation. Anti-adhesive Teflon[®] -like monolayers are vital for the failure-free separation of stamp and substrate. The tribological properties of physisorbed and chemisorbed perfluorosilanes have been studied with the expected conclusion that chemisorption leads to more robust SAMs.²³ Covalently tethered self-assembled monolayers (SAMs) have several advantages over ion-sputtered and plasma deposited PTFE-films including minimal impact on feature size and longevity.15,24–27 As well as high stability with respect to both heat and chemical attack, saturated perfluorocarbons offer the lowest dielectric constants and surface energies of any liquid.²⁸ Many perfluoro SAMs have been studied on a variety of surfaces including the alkanoates on zirconia,²⁹ the silanes on silicon oxide, $30-32$ and thiolates on gold and other coinage metals.³³ Short, linear perfluoro chains tend to adopt a zig-zag (all-trans) conformation and therefore occupy a geometric cylinder whereas chains longer than 12 carbons tend to take a helical form.³⁴ The perfluorocarbons are more rigid than their comparatively flexible

hydrocarbon counterparts.³⁵ Despite their rigidity, intermolecular interactions provide for complex behaviour of fluorocarbon Langmuir monolayers $36,37$ and solid–solid phase transitions are observed.³⁸ Hydrofluoroalkyl chain behaviour and properties are usually intermediate between the corresponding saturated hydrocarbon and perfluoroalkyl species.²⁸

Very recent ¹⁹F NMR studies of perfluoroalkanoate SAMs on zirconia suggest that there is no evidence of chain melting at temperatures well above the T_m of bulk materials and that enhanced SAM mobility is a result of molecular reorientations around the long chain axis.²⁹ This finding may be important for the understanding of anti-stiction SAM behaviour in hotembossing where adhesion, with components both normal and parallel to the displacement, occurs over complex topology at temperatures typically ranging from 40 \degree C to 300 \degree C.

Experimental

The stamp–substrate interaction was modelled in two phases. In the first instance, individual silicon wafer pieces were functionalized with four different silanes: *n-*octyltrichlorosilane (OTS), 1,1,2,2,-tetrahydroperfluorooctyl-trichlorosilane (F6), 1,1,2,2,-tetrahydroperfluorodecyl-trichlorosilane (F8), and 3-(heptafluoroisopropoxy)-propyltriethoxysilane (F3). For the hydrofluorosilanes, the abbreviation refers to the number of fluorinated carbon atoms. Silicon [111] wafers (Silicon Quest International) were piranha-cleaned and placed in a Pyrex vacuum chamber. Following three atmosphere exchange cycles with nitrogen gas, silane was introduced and the chamber atmosphere pressure was reduced leading to the vapour-phase surface functionalization of anti-adhesive SAMs (see Scheme 1). Despite the very high probability of inter-silane polymerization and complex film formation, 39 we chose the trichlorosilanes due (i) to the availability of the hydro(fluoro)alkyl series and (ii) to normalize the experiment with respect to the silanization process to focus on the release-layer–polymer interaction. In related work using F6 as a release layer applied as above (once only) to a single

Scheme 1 Structures of the four silanes examined in this study: perfluoro-isopropoxyethylsilane (F3), 1,1,2,2-tetrahydroperfluoro-octylsilane (F6), 1,1,2,2-tetrahydroperfluorodecylsilane (F8) and octylsilane (OTS).

stamp, we have observed several hundred embossing cycles with no substantial decrease in anti-adhesive properties.¹³

Static contact angle measurements were determined with 18.2 M Ω cm water (MilliO) using a microsyringe with the submerged-point technique.⁴⁰ Preliminary adhesion measurements were obtained between bare, used-as-received Veeco NP contactmode tips (nominal spring constant and radius of curvature 0.58 N m⁻¹ and 20-60 nm respectively) and the silanized wafers on a Veeco NanoScope IV MultiMode AFM. The wafers were imaged to determine RMS surface roughness (Table 1).

Following the preliminary experiments to determine functionalization and AFM protocols, Veeco NP contact-mode AFM tips were $O₂$ plasma treated and silanized as described above. The tips were characterized by FEG-SEM microscopy before and after functionalization and were determined to be free of significant physical defects. Thin-films (1 µm) of poly(cyclic olefin), Zeonor 750R, were spin-coated (Brewer CEE 100) from chlorobenzene (Aldrich) on silicon wafers. Force-curves for each of the silanized tips were determined at several temperatures spanning the glasstransition of the polymer ($T_g \sim 72$ °C). Five measurements at each of three locations were obtained for each data point in Fig. 2. The standard deviation of measurements for each datapoint was less than 5 nN.

All supported polymer films were cleaved from one film-covered silicon wafer. AFM deflection set points were minimized to avoid significant polymer penetration and to normalize the interaction. Force-curve conditions were adapted from the Veeco Metrology Group.⁴¹ The substrate holder, substrate, polymer and tip assembly were conditionned at 20, 60, 80 and 100 $^{\circ}$ C with several hours of equilibration before measurements were acquired at each temperature.

Fig. 2 VT-CFM data for the silane-decorated SPM tip *vs* polymer (PCO) interaction at temperatures above and below the polymer $T_{\rm g}$.

Results and discussion

Water drop contact angles (see Table 1) on each of the silanized substrates indicated a hydrophobic surface, and the data were therefore consistent with the formation of organosilane SAMs. Contact angle measurement is a subject of some discussion 40 and comparison of data among devices and techniques is prone to error; however, in our hands, our device (Kernco) provided results reproducible within 2° . Of note was the comparatively high angle associated with the linear hydrofluorocarbons as compared with the lower contact angle associated with the branched hydrofluoroalkylether. The difference was attributed to: (i) the enhanced reactivity and potentially denser coverage of the linear trichlorosilylhydrofluorocarbons as well as (ii) steric stabilization of the SAM, and (iii) the possibility of hydrogen bonding to the oxygen atom in the perfluoroisopropoxy headgroup.

The on-wafer SAMs were further characterized by chemical force microscopy $(CFM)^{42}$ at room temperature as described above. The adhesive force between a used-as-received AFM tip $(0.58 \text{ N m}^{-1}$ cantilever) and each SAM was measured, the largest force being more than 200 nN for OTS. This saturated hydrocarbon-tailed silane is frequently employed to form lowenergy surfaces, however perfluorination provides even lower energy. Among the perfluorosilanes, the measured adhesion force increased from 55 nN to 117 nN as the contact angle decreased from F6 to F8 and finally to an F3 SAM (see Table 1). This result suggests that the quality and density of the SAM, which is related to the reactivity of the parent silane and its footprint at the surface, has an important effect on tip-SAM adhesion.⁴³ The silanized surfaces were also imaged by AFM since Schift *et al.*³¹ and Fadeev *et al.*³⁹ have reported on the polymerization of di- and tri-dentate silanes. We did not observe substantial surface nano-topology due to silane-silane polymerization and speculate, therefore, that our slow, low-concentration vapour-phase functionalization favoured surface pseudo self-assembly polymerization thereby reducing the possibility complex, multilayer film formation.

Since HEL involves the three-dimensional texturing of a thermoplastic polymer resin above its $T_{\rm g}$, we employed the variable temperature (VT) module of our multi-mode NanoScope IV to heat the substrate and SPM scanner from 20 \degree C to 100 \degree C. Multiple force curves were obtained for OTS, F6, F3 and F8-silanized AFM tips and the resulting adhesion forces are shown in Fig. 2. At 20 \degree C, the adhesion forces for all silanes fell within roughly 20 nN. As the temperature was raised towards T_g , the pull-off force for the OTS and bare tips increased substantially through the transition. At temperatures below and near the $T_{\rm g}$, the adhesion forces for the shorter hydrofluorocarbon-decorated tips (F3 and F6) increased slightly. At 100 $^{\circ}$ C, nearly 30 $^{\circ}$ C above the PCO $T_{\rm g}$, the adhesion forces increased for all tips since the polymer softened, SAM mobility increased, and the tip-polymer interaction became more significant. In the temperature range critical to successful de-embossing with this PCO (cooling from $T_{\rm emb}$ to $T_{\rm de-emb}$, the data may be divided into two groups: the non-hydrofluorinated tips (OTS and bare) and the short-chain hydrofluorinated tips (F3 and F6). Curiously, the longer-chain hydrofluorinated tip (F8) exhibits cross-over behaviour above and below *T*^g .

Roughness data (Table 1) and VT-CFM data suggest that the SAM coverage for the longest-chain hydrofluorosilane was imperfect, perhaps due to the lower relative availability of the silane headgroup as a result of steric hindrance during functionalization. Lower vapour-phase silane concentration for this highest-boiling silane may have also been a contributing factor, though long reaction times (several hours), reduced pressure and elevated temperature were employed to minimize this source of error. It is possible that this SAM undergoes a phase transition at or near 80 \degree C where there is a discontinuity in the VT adhesion force curve.

As compared with the hydrofluoroalkylsilanes, the alkylsilane indicated a strong interaction with the polymer thin-film. We have treated similar systems where brushes are in contact with polymer matrices in terms of χ , the interaction parameter.⁴⁴ Given that an OTS brush presents as a saturated hydrocarbon surface and the polymer substrate is also a saturated hydrocarbon, γ is favourable and it is unsurprising that the highest adhesion forces were measured for this system. Indeed the conditions were not unfavourable for a polymer 'weld'. The bare, as-received tip also adhered relatively well to the PCO film above the PCO T_{g} , presumably due to its relatively high surface energy.

As we routinely observe empirically with HEL, the adhesion forces measured quantitatively for the fluoroalkylsilanes indicated far better release properties, however the results require some interpretation. Based on the evidence in Table 1 for SAM quality, one might expect that F6-silanized tips would provide the lowest adhesion force. We observe instead that the lowest force corresponded to the F3-tip. We suggest that this may be due to the comparatively flexible perfluoroisopropoxy headgroup of this silane, which presents two perfluoromethyl groups per tethered silane so that even if the tether density of this silane is not as high as the F6 and F8 silanes on a flat surface, the local effect is much greater. Furthermore, the flexible ether linkage may have an important role to play in light of the stiffer fluoroalkyl species which appear to be not appreciably mobile even above their bulk melt temperature and are dominated by about-axis rotation.²⁹

Finally, whereas the data in Table 1 were determined for silanized flat surfaces, the VT-CFM data were derived from functionalized AFM tips where the interaction is limited to the tip point. Since the steric hindrance to brush formation is substantially reduced with this geometry⁴⁵ it is probable that the actual footprint per F3 silane molecule is somewhat reduced as shown schematically in Fig. 1D.

Conclusions

HEL is a promising alternative micro- and nanofabrication technique with the capacity to replicate sub 10 nm features, but high throughput, low-cost, and high-yield depends on appropriate stamp design, substrate selection, embossing parameters and is critically dependent on interfacial interactions during the embossing stroke and de-embossing process. We routinely replicate lines and posts with maximum dimensions from several cm to 50 nm using stamps that have been F6 silanized. These stamps usually provide more than 100 embossing cycles before adhesion and breakage becomes an issue. The most common challenge we observe with the technique is adhesion between the stamp and the substrate, hence this study of the nature of release-layer interactions by VT-CFM.

Here we have reported: (i) appropriate chemistry for the silanization of silicon wafer substrates verified by contact angle measurements; (ii) a model system to characterize the wafer–silane interface where an as-received SPM tip was brought into contact with a functionalized wafer and pull-off forces were measured; (iii) characterization of the silane–polymer interface where silanized SPM tips were employed to measure pull-off forces from a thermoplastic polymer film above and below the polymer glass transition temperature.

The results suggest that release agents should be chosen as a function of the topology they are to functionalize. Perfluoroisopropoxy groups are well suited to features with high curvature and *n*-alkyl perfluorosilanes are apparently better adapted to planar surfaces. Furthermore, the data suggest that even shorter-chain silanes may provide better release layers since the silane footprint is reduced and the resulting SAM may have fewer defects.

The longest chain investigated, a 1,1,2,2-tetrahydroperfluorodecyl silane suggested interesting adhesive behaviour below the T_g of the PCO with adhesion-force cross-over as discussed above. The challenges inherent in measuring nano-adhesion at elevated temperatures require that ongoing and future work will compare results from other VT-CFM instruments to further characterize and understand the effect of AFM tip functionalization and the tip-polymer interactions above the polymer T_g as a model system for hot embossing lithography.

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